
Effect of Vanadium Doping on Microstructure and Dielectric Behavior of $\text{CaCu}_3\text{Ti}_4\text{O}_{12}$ Ceramics

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Abstract: In this work, effect of vanadium doping of $\text{CaCu}_3\text{Ti}_4\text{O}_{12}$ (CCTO) on microstructure and complex dielectric constant over wide frequency (100 Hz-1 MHz) and temperature (0°C – 160°C) ranges has been studied. The vanadium doping of CCTO system results in an increase of grain size, the grains being surrounded by melted-like grain boundaries. Real parts of dielectric constant of all samples are similar at low frequency (<1 kHz). In doped samples, above 1 kHz, a relaxation appears which is evidenced by a drop of real part of permittivity and a peak of its imaginary part. This relaxation phenomenon is very significant at relatively low doping rates and then decreases again as vanadium content increases. AC conductivity behavior of vanadium-doped CCTO can be divided in three regions depending on conduction processes. The calculated activation energies were close to 0.46 eV.

Keywords: Ceramics, Solid State Reaction Method, Microstructure, Dielectric Properties, Electrical Conduction

1. Introduction

Research on new high permittivity materials for the enhancement of the performance of capacitors has led to the discovery of a new class of materials based on perovskite-related compounds like the prominent $\text{CaCu}_3\text{Ti}_4\text{O}_{12}$ (CCTO). This material shows a number of interesting properties with the possibility of a large number of technological applications in the field of microelectronics [1]. The principal application for such a dielectric ceramic is for capacitors in electronic circuits and as electrical insulators [2]. Indeed, it presents a high dielectric constant almost independent of frequency in a huge frequency range (10^2 - 10^6 Hz) as well as has a high thermal stability over a wide temperature range (100-600 K) [3, 4, 5]. However, the properties of bulk samples are not well understood and are the object of numerous discussions. Nevertheless, it seems more or less accepted that the origin of the high dielectric constant is due

to extrinsic effects, like Surface Barrier Layer Capacitance (SBLC) [6] or Internal Barrier Layer Capacitance (IBLC) [1, 7, 8]. This last theory reported that semi-conductor grains and insulating grain boundaries lead to this large value of permittivity. It is well known that the dielectric properties of CCTO strongly depend on processing conditions during sample preparation, on oxygen stoichiometry, on sintering additive, as well as on small amounts of cationic doping [9, 10, 11]. In all cases, to improve the properties, the grains must be semi-conductor. Adams and al. proposed that the semi-conductivity could come from the generation of oxygen vacancies [12]. Li and al. suggested that Cu^{2+} reduces to Cu^+ during the synthesis with a small substitution of Ti^{4+} on Cu sites. To compensate the charge balance, Ti^{3+} would appear within the material, thus affecting the conductivity [13].

For the present work, we directly added V_2O_3 powder with weight ratio of 0.5, 1, 3 and 5 % into CCTO powder and sintered these mixtures. We have investigated the structural,

dielectric properties and conductivity as a function of V_2O_3 content.

2. Experimental Procedure

Single phase $CaCu_3Ti_4O_{12}$ (CCTO) powders were prepared through a conventional solid state reaction route by mixing appropriate amounts of high purity $CaCO_3$ (99.98%), TiO_2 (99.9%), and CuO (99.99%) raw powders previously dried at $400^\circ C$ for 24 hours. The starting materials were mixed and ball milled two days in isopropanol, followed by calcination at $950^\circ C$ for 12 h. The x-ray diffraction showed that the calcined powders were single phase. The calcined CCTO powders were then mixed with 0.5, 1, 3 and 5% in mass of V_2O_3 powder and then compacted into pellets by cold isostatic pressing followed by sintering in air at $1050^\circ C$ for 24 h.

X-ray diffraction (XRD) analysis was performed (D8 diffractometer, Bruker) using $Cu K_\alpha$ radiation of wavelength $\approx 1.54 \text{ \AA}$. The diffraction patterns were recorded in 2θ range of $10 - 110^\circ$ with a step of 0.02° . Rietveld refinement of the crystal structures was carried out with the FullProf software [14].

The morphology and microstructural analysis of the powders and pellets were performed by scanning electron microscopy (SEM) using a Hitachi 4160-F instrument.

Gold was deposited on both surfaces of the sintered disks and fired at $500^\circ C$ for 1 hour. The sample pellets were 12 mm in diameter and about 1 mm in thickness. The dielectric properties and electric conductivity were measured over a broad frequency range (100 Hz–10 MHz) using an Agilent 4294A impedance analyzer at various temperatures.

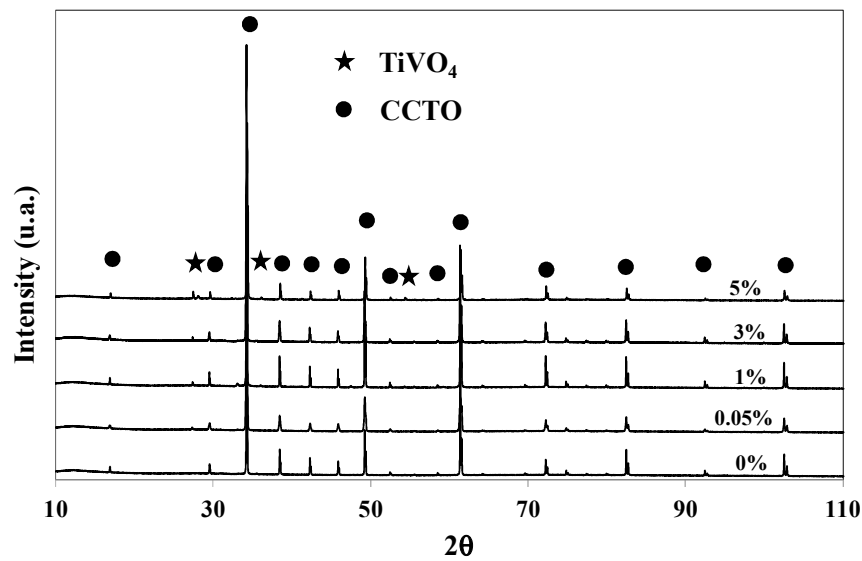


Figure 1. XRD patterns of pure and vanadium-doped CCTO samples.

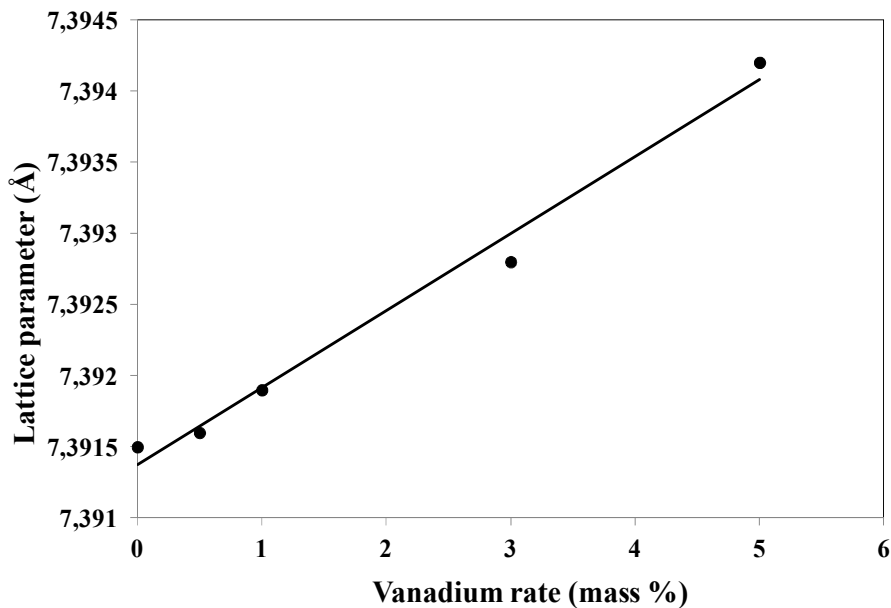


Figure 2. Lattice parameter depending on V rate.

3. Results and Discussions

3.1. X-ray Analysis

The X-ray diffraction (XRD) patterns of the samples are shown in Figure 1 for different V_2O_3 content. The peaks on diffraction patterns can be indexed to perovskite-related structure of CCTO with the cubic space group Im-3 . However, impurities of TiVO_4 are found in the 5% doped ceramics with a percentage of about 3-4 %, indicated by the symbol \star . Consequently, only samples with doping up to 3 mass% were considered for further analysis. V_2O_3 doping has a slight effect on the crystal structure of CCTO which is evidenced by an increase of the lattice parameter a of the cubic phase as doping increases (Figure 2). The evolution of a indicates that a part of Ti has been substituted by vanadium in the CCTO structure. Indeed, the volume evolution follows Vegard's law for the small doping. Taking account the radii and the valences of the cations, it seems that vanadium substitutes the octahedral Ti site.

3.2. Microstructure Analysis

Figures 3a, 3b, 3c, and 3d show the SEM images of the surface of 0, 0.5, 1, 3 mass% V_2O_3 -added CCTO sample, respectively. In figure 3a, one can observe that the pure CCTO compound has a microstructure consisting of closely linked grains with a size close to 3-4 μm . The microstructure changes significantly with the addition of V_2O_3 (Figure 3). Figure 3b (0.5 mass%) exhibits a non-homogeneous microstructure with large grains ($\approx 20 \mu\text{m}$) surrounded by small ones (5-10 μm). Figure 3c and 3d (1 and 3 mass%) exhibit bigger grains than previously, surrounded by some melted-like grain boundaries.

It can be concluded that V_2O_3 doping increases the grain size of CCTO as evidenced by the microstructure shown in figure 3, these findings being similar to results obtained by Fang [15] and Brizé [9] with other dopants.

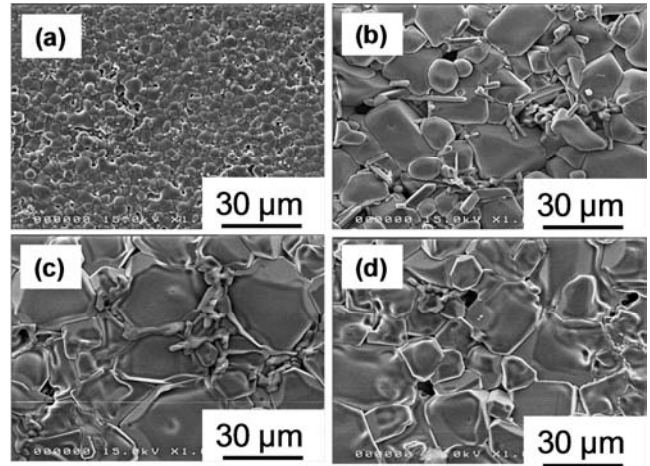


Figure 3. SEM micrographs of pure (a), 0.5 mass% (b), 1 mass% (c) and 3 mass% (d) V_2O_3 -doped-CCTO samples.

3.3. Dielectric Properties

Figure 4 shows the frequency variation of the real part of dielectric constant ϵ' of vanadium-doped CCTO ceramics: globally, a decrease is observed when frequency increases. Dielectric constant of pure and doped CCTO samples appear to be similar at low frequency ($< 1 \text{ kHz}$) with a value over 10^5 at room temperature, but it drops strongly over 1 kHz for doped samples to reach approximately 100.

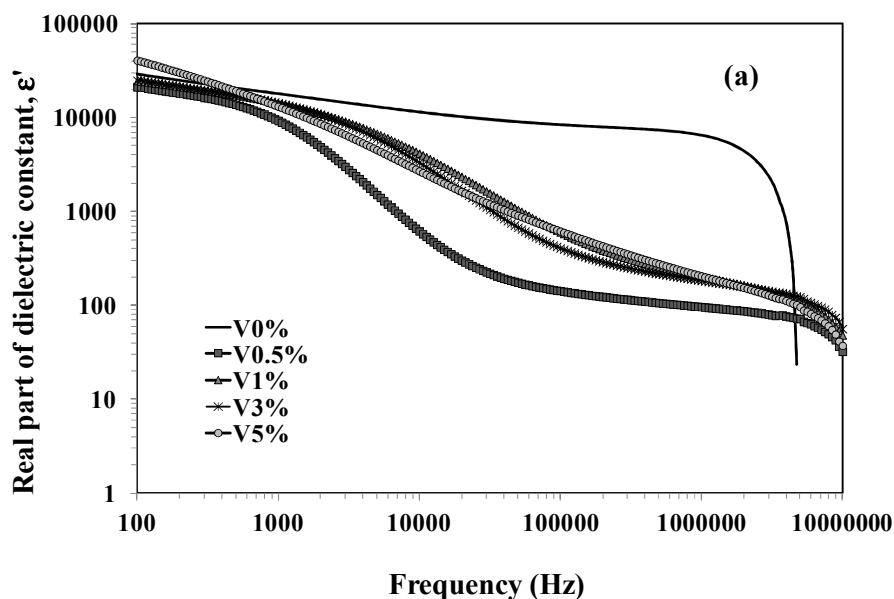


Figure 4. Variation of real part of dielectric constant with frequency for pure and vanadium-doped samples at room temperature.

The dependence of the complex dielectric constant with frequency reveals the existence of a relaxation process in the range 1 kHz to 1 MHz for doped samples, a phenomenon unobserved in pure CCTO. Un-doped CCTO exhibits a slightly decreasing

real part of dielectric constant followed by a very strong decrease at high frequency [16]. The V_2O_3 doping also affects the loss tangent ϵ''/ϵ' (Figure 5), representing the AC conductivity, leading to its increase in the frequency range 1kHz-1MHz for all doped samples relatively to the un-doped one.

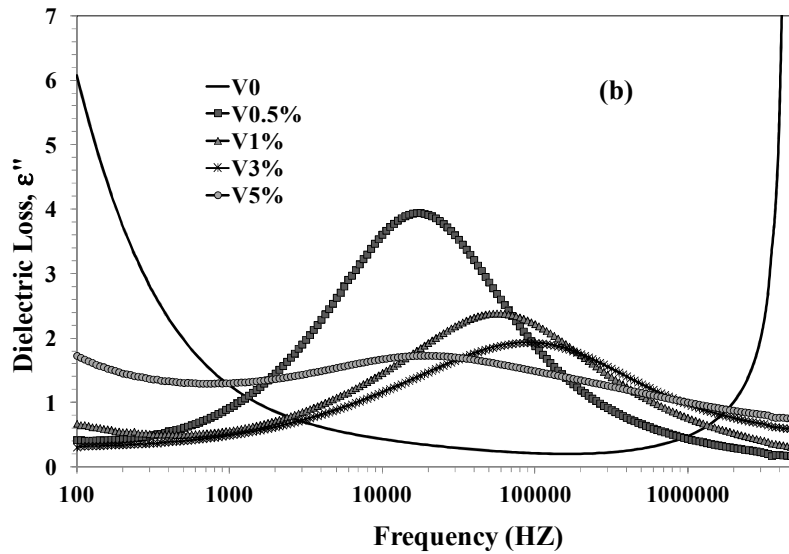
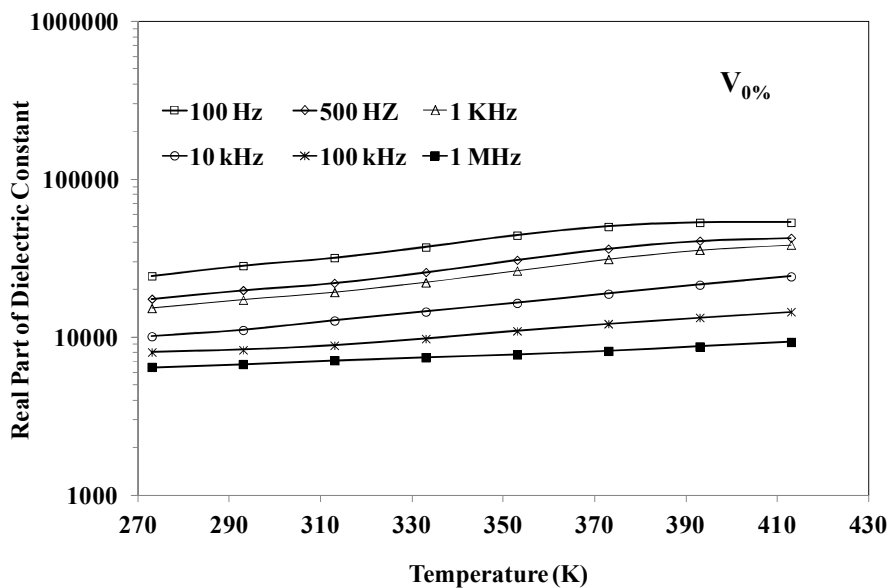


Figure 5. Frequency dependence of dielectric loss for pure and vanadium-doped CCTO samples at room temperature.

Real part of dielectric constant for pure CCTO shows weak temperature dependence [17]. With the addition of vanadium, a relaxor behavior corresponding to a decrease of ϵ' versus frequency associated with a peak in loss tangent becomes quite significant (Figure 6). Globally, in presence of vanadium, the magnitude of dielectric constant is decreased. The evolution of the real part of dielectric constant can be divided in two groups relative to the frequency. For frequencies up to 1 kHz, dielectric behavior is similar to that shown by pure CCTO on the entire temperature range. This behavior can be attributed to a Debye-like relaxation, generally associated to surface layers interfacial polarization. Similar results were reported by other authors [18, 19]. Recently, some authors [20] attributed this relaxation to a

trap state related phenomenon: the high permittivity in the low frequency range of CCTO could be attributed to the trap states that exist at the electrode surface. Relaxation time is long enough to allow traps to respond, which could explain a huge permittivity at low frequency. When frequency is higher than 1 kHz, relaxor behavior is more pronounced for vanadium-doped CCTO, characterized by a decrease of the real part of dielectric constant on the entire temperature range. Vanadium-doped samples show a relaxation at higher frequencies and higher temperatures, which may be attributed to hopping of trapped carriers. The relaxation peak shifts towards higher temperatures when frequency increases. When vanadium content increases, relaxation peaks are shifted towards lower temperatures.



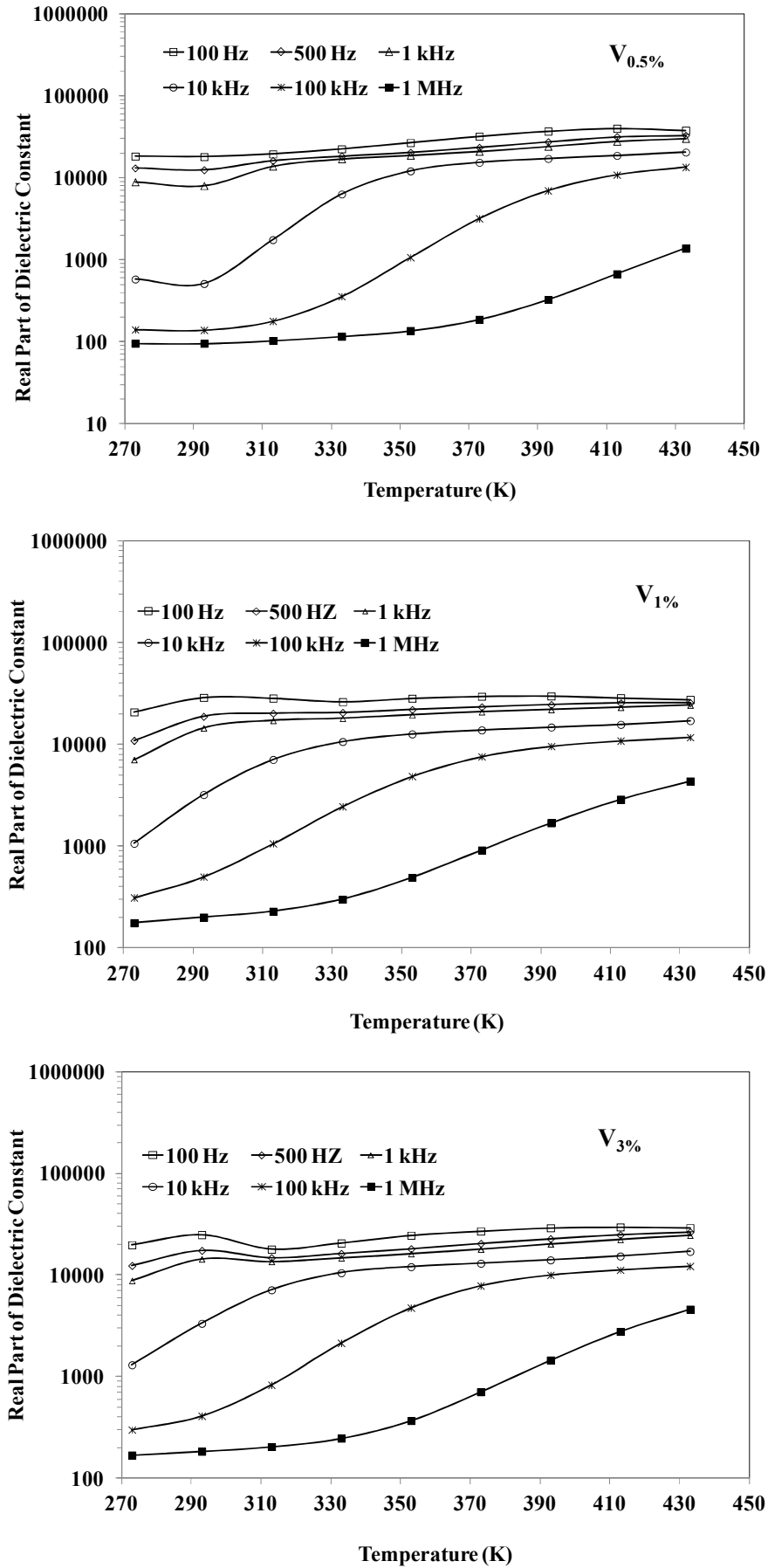


Figure 6. Variation of real part of dielectric constant ϵ' with temperature at different frequencies for pure and vanadium-doped CCTO samples.

In Figure 7 it can be seen that dielectric losses increase as the temperature increases, indicating the semiconducting nature. For frequencies below 1 kHz, the dielectric losses decrease significantly in the presence of vanadium compared with the un-doped sample. Above 1 kHz, the dielectric loss is lower for pure CCTO, but peaks appear for doped compounds, indicating the relaxation phenomena mentioned above. The relaxation peak move to higher temperatures when the frequency increases and their amplitude decreases when the vanadium content increases.

Let us now consider the AC conductivity of different samples according to their V_2O_3 content. This conductivity results from hopping conduction and increases with frequency in disordered solids [21].

Equation (1) gives the expression of the total conductivity of a solid:

$$\sigma = \sigma_{ac} + \sigma_{dc} \quad (1)$$

with σ_{ac} , the AC conductivity, originating from hopping conduction and σ_{dc} the DC conductivity resulting from conduction band.

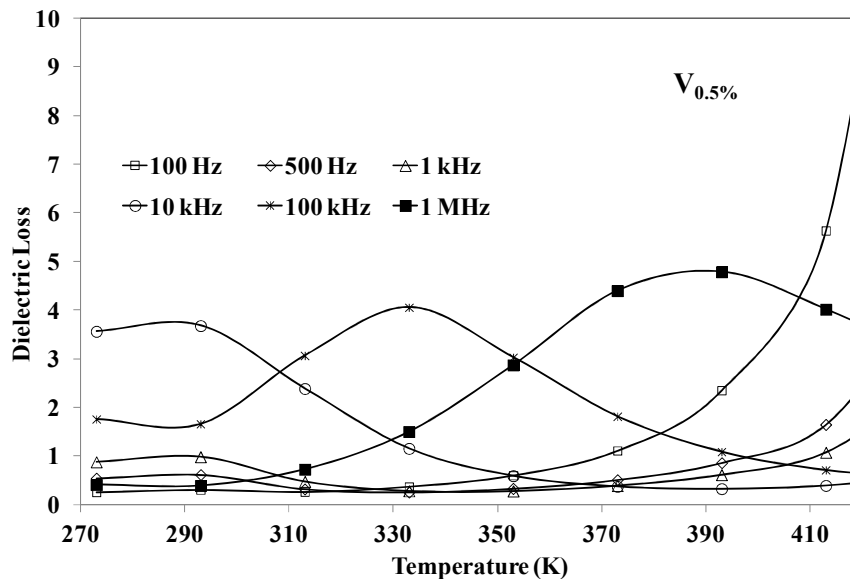
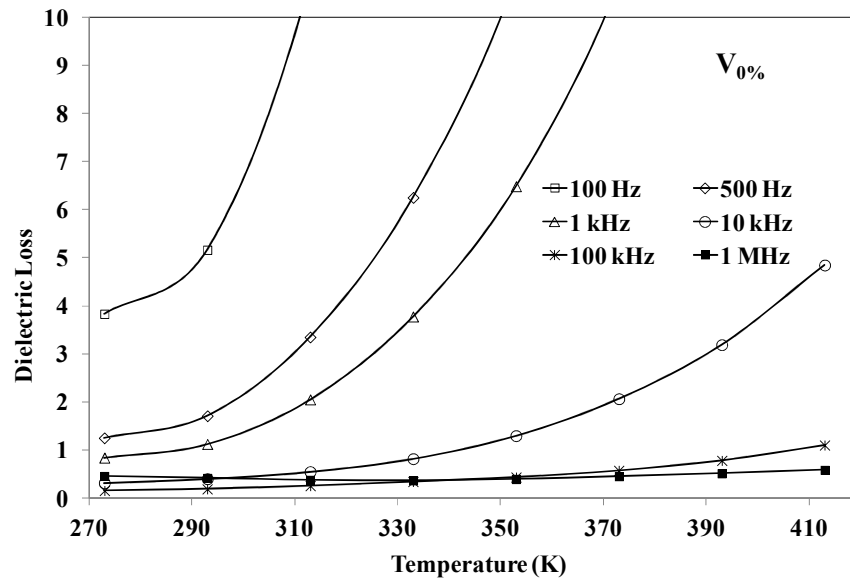
Here, σ_{ac} was calculated using Equation 2:

$$\sigma_{ac} = 2\pi f \epsilon_0 \epsilon' \tan(\delta) \quad (2)$$

where f is the frequency, ϵ_0 the permittivity of vacuum, ϵ' the real part of dielectric constant and $\tan(\delta)$ the dielectric loss tangent. Figure 8 shows the frequency dependence of σ_{ac} . The AC conductivity obeys the empirical formula of the frequency dependence given by the AC power law [15]

$$\sigma_{ac} = A f^n \quad (3)$$

where A and n are constants, which depend on both the temperature and composition; n is dimensionless constant having values between 0 and 1.



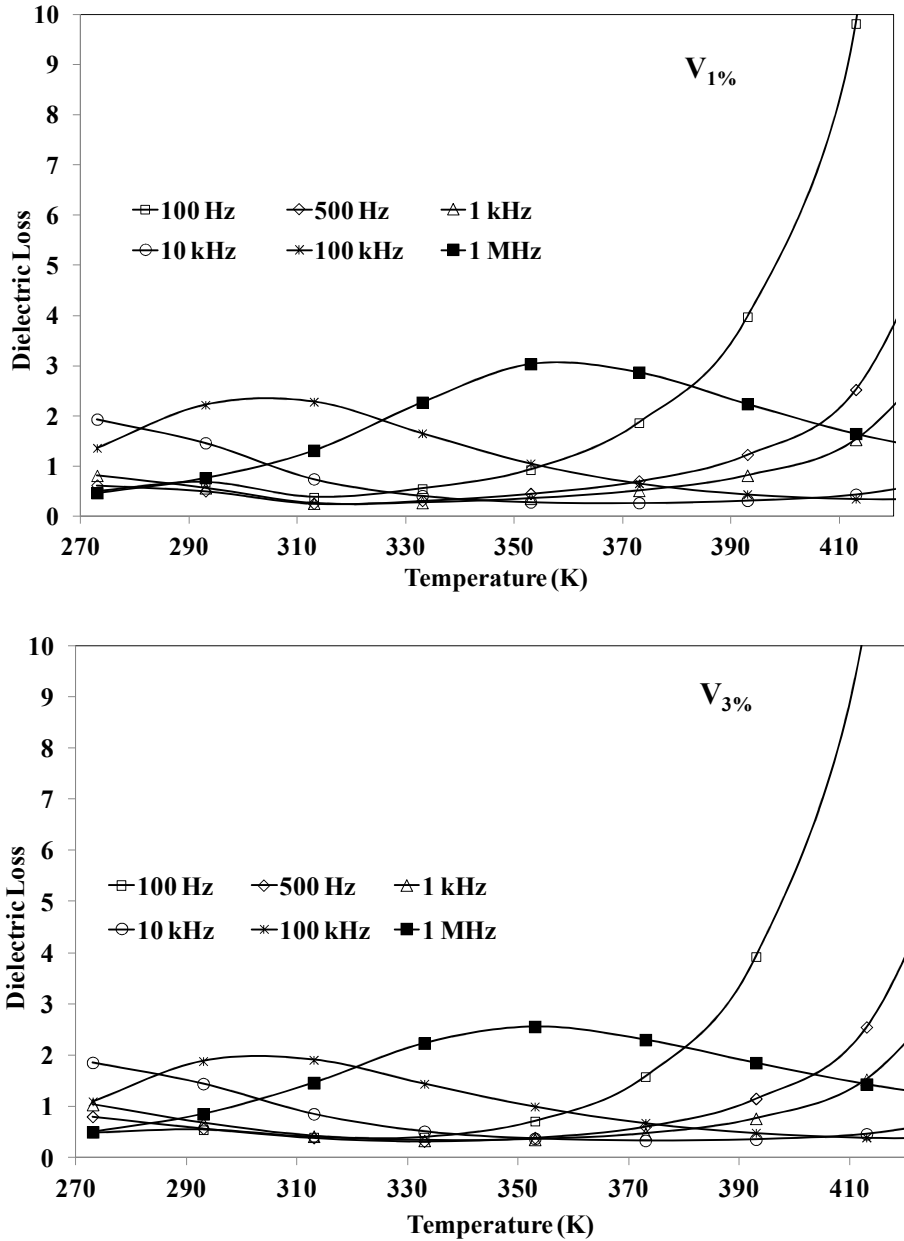


Figure 7. Variation of dielectric loss tangent with temperature at different frequencies for pure and vanadium-doped CCTO samples.

AC conductivity as a function of frequency can be divided into three regions: region I at low frequencies (100 Hz - 1 kHz), region II at intermediate frequencies (1 kHz – 100 kHz) and region III at high frequencies (above 100 kHz). Let us first consider pure CCTO. In region I, the curve is practically constant and remains equal to the DC value, because the electric field does not influence the hopping conduction. In region II, the conductivity increases with frequency. This is due to the mechanism of hopping conduction that appears in region II and is enhanced in region III. For doped compounds, the AC conductivity starts at lower values, then increases strongly in region I and finally increases very slightly with frequency in regions II and III towards saturation. For the doped samples, the electric field

under 1 KHz is sufficient to influence the hopping conduction, which is not the case for pure CCTO. This result is in good agreement with that observed in Figure 4.

Properties of CCTO have been explained assuming it is made of semiconducting grains and insulating grain boundaries [7]. Here, it is first observed (Figure 8) that vanadium doping increases the resistivity of CCTO ceramics. AC conductivity is independent of frequency if a single charged species moves in an infinite lattice of identical potential wells. Secondly, the conductivity increases and saturates at high frequency when a single particle hopping to and from a double well with infinite height [22], which is also in favor of the assumption above.

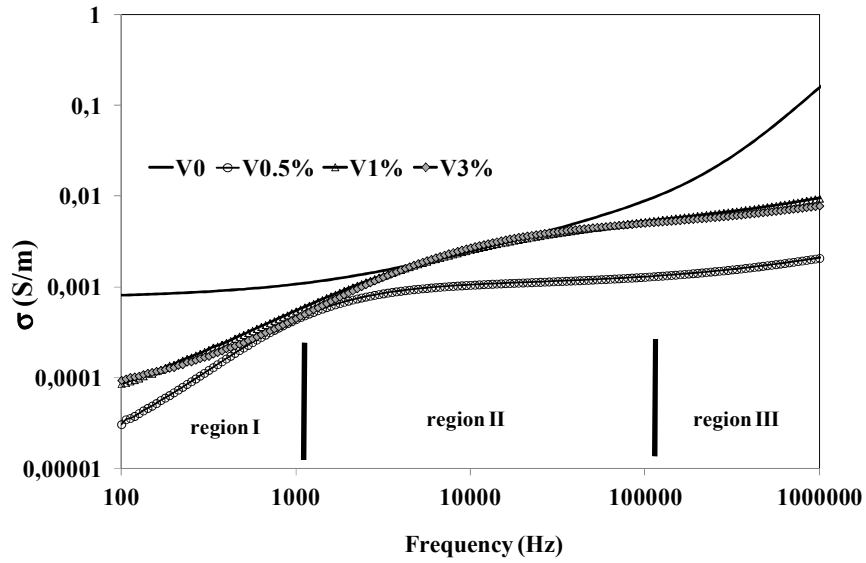
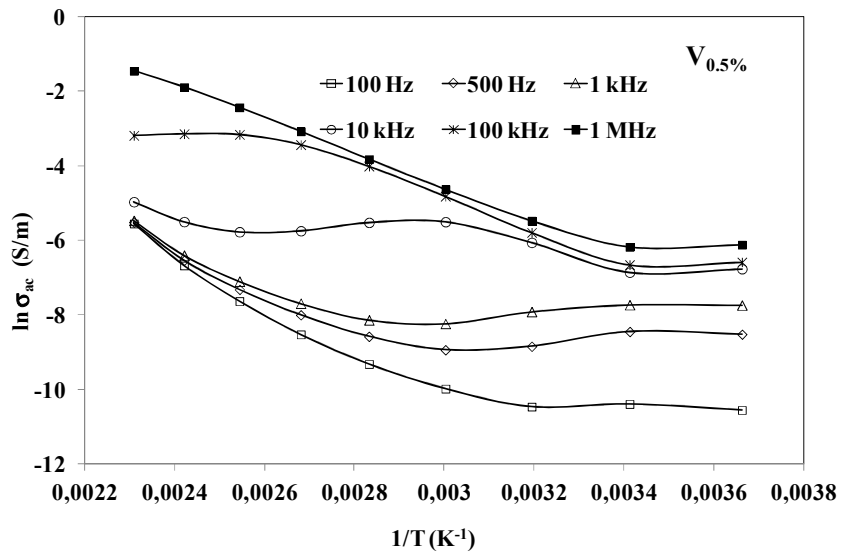
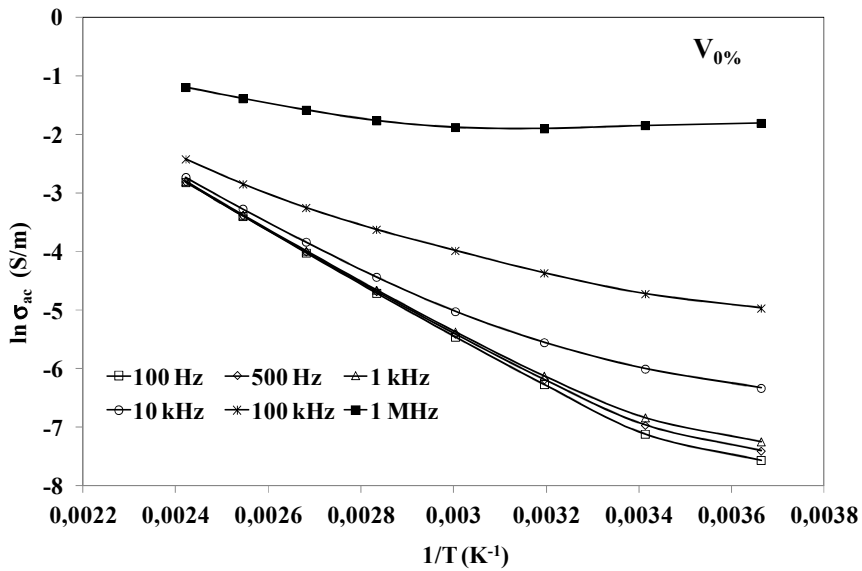


Figure 8. Variation of AC conductivity, σ_{ac} , with frequency at room temperature for pure and vanadium-doped CCTO samples.



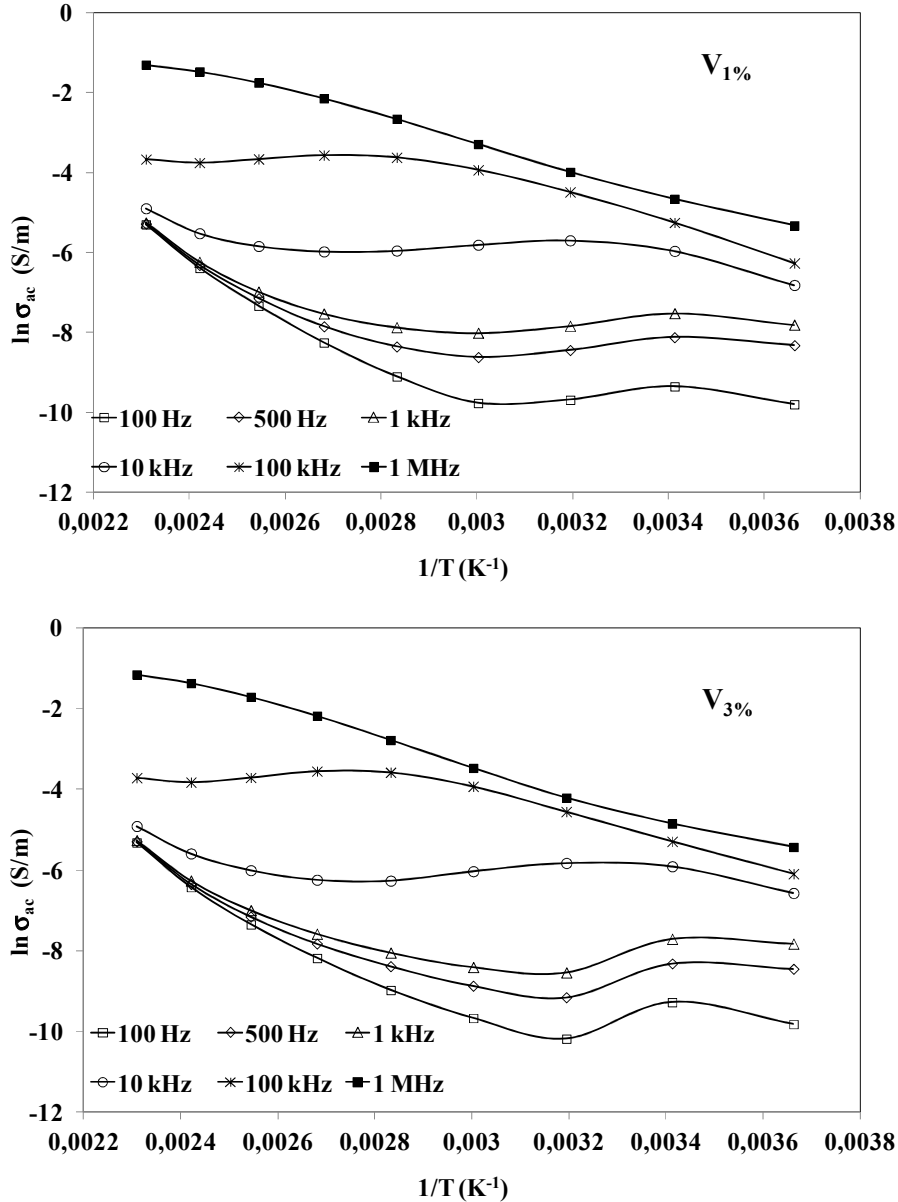


Figure 9. Arrhenius plot ($\ln \sigma_{ac}$ as a function of $1/T$) for pure and vanadium-doped CCTO samples.

Figure 9 shows the Arrhenius plots ($\ln(\sigma_{ac})$) as a function of $1/T$ for un-doped and vanadium-doped CCTO at different frequencies. From this plot, according to Arrhenius principle, the value of activation energy can be deduced:

$$\sigma_{ac} = \sigma_0 \exp(-E_a/k_B T) \tag{4}$$

where σ_0 is the pre-exponential factor, E_a the activation energy, k_B the Boltzmann constant (8.61×10^{-5} eV K^{-1}) and T the absolute temperature.

Real and imaginary parts of the dielectric constant of vanadium-doped samples are strongly temperature dependent, due to a relaxation process and the activation energies can be estimated by using the classical Arrhenius relation [23]:

$$F_p(T) = \nu_0 \exp(-E_a/kT) \tag{5}$$

where $F_p(T)$ is the frequency of the peak of dielectric loss (Figure 7) at temperature T , ν_0 the pre-exponential factor or frequency factor, E_a the activation energy of the relaxation processes obtained from straight inclination ($-E_a/k_B$). From Figure 7, the activation energies of the doped samples were calculated from Equation 4 and Figure 10 shows the plot of the relaxation frequency (F_p) as a function of $1000/T$. Activation energy obtained for each doped compound was around $E_a = 0.46$ eV. Sinclar *et al.* [7, 8] found two types of resistances on bulk CCTO: the bulk (R_b) and the grain boundary (R_{gb}) with activation energies of 0.6 eV and 0.08 eV respectively. The first one is close to the values found here. This suggests that the relaxation observed in our temperature and frequency ranges is related to the bulk resistance. Then the conductivity increases at high temperatures.

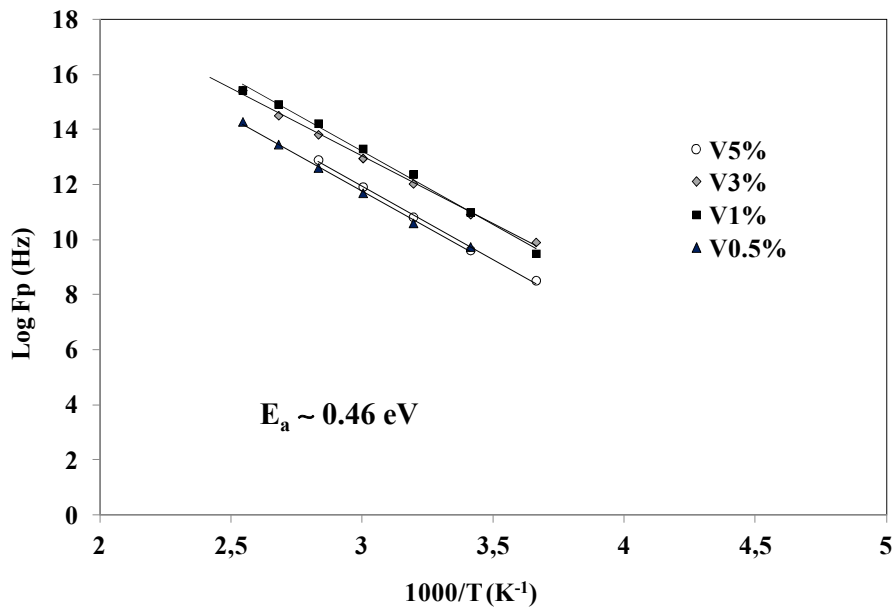


Figure 10. Activation energy of relaxation processes of vanadium-doped CCTO samples.

4. Conclusion

Vanadium doping of CCTO increases its lattice parameter and the grain size by partial substitution of titanium. At low frequency and room temperature, dielectric constants of undoped and doped CCTO are almost identical. In the presence of vanadium, above 1 kHz, it decreases due to a relaxation phenomenon that appears in our range of frequencies and temperatures. The relaxation peak moves towards lower temperatures when the vanadium content increases. AC conductivity has an effect at low frequency for doped samples while it only starts to play a role at high frequency for un-doped samples. The calculated activation energies were around $E_a = 0.46$ eV. This value is in fair agreement with values reported in the literature for bulk CCTO samples [7, 8] and CCTO film [17]. CCTO has been identified as an interesting material due to semiconducting grains and insulating grain boundaries [7]. Vanadium doping allows the relaxation to be shifted from very low frequencies to the 10-100 KHz region, which leads to better dielectric properties at low frequencies (up to 1kHz), but degrades them in the mid-frequency range.

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